

United States Patent and Trademark Office

United	States Patent and Trademark Office	
Address:	COMMISSIONER FOR PATENTS	
	P.O. Box 1450	
	Alexandria, Virginia 22313-1450	

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/751,831	01/05/2004	Sadanand V. Deshpande	FIS920030078US2 (16422A)	3568
23389	7590 03/16/2005		EXAM	INER
SCULLY SCOTT MURPHY & PRESSER, PC 400 GARDEN CITY PLAZA			WOJCIECHOWICZ, EDWARD JOSEPH	
SUITE 300	CHITEMEN		ART UNIT	PAPER NUMBER
GARDEN CITY, NY 11530			2815	

DATE MAILED: 03/16/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
Office Action Summary		10/751,831	DESHPANDE E	T AL.			
		Examiner	Art Unit				
		Edward Wojciech					
Period fo	The MAILING DATE of this communica or Reply	tion appears on the cover	sheet with the correspondence a	ddress			
THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICATION of the may be available under the provisions of SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) do period for reply is specified above, the maximum statutore to reply within the set or extended period for reply will, reply received by the Office later than three months after end patent term adjustment. See 37 CFR 1.704(b).	ATION. 7 CFR 1.136(a). In no event, however ation. ays, a reply within the statutory mining period will apply and will expire Soby statute, cause the application to	ver, may a reply be timely filed mum of thirty (30) days will be considered tim IX (6) MONTHS from the mailing date of this become ABANDONED (35 U.S.C. § 133).				
Status	÷						
1)	Responsive to communication(s) filed of	on					
2a) <u></u> □	This action is FINAL . 2b)	oxtimes This action is non-fina	l. *				
3)	Since this application is in condition for	·	•	ne merits is			
	closed in accordance with the practice	under <i>Ex parte Quayle</i> , 1	935 C.D. 11, 453 O.G. 213.				
Disposit	ion of Claims						
5)□ 6)⊠ 7)□	4) Claim(s) 15-20 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 15-20 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.						
Applicat	ion Papers						
9)[The specification is objected to by the E	xaminer.					
10)	The drawing(s) filed on is/are: a	I∏ accepted or b)☐ obje	ected to by the Examiner.				
	Applicant may not request that any objection	n to the drawing(s) be held i	n abeyance. See 37 CFR 1.85(a).				
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority (ınder 35 U.S.C. § 119		•				
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
Attachmen	t(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date							
3) 🛛 Infor	mation Disclosure Statement(s) (PTO-1449 or PTo r No(s)/Mail Date <u>11-17-04</u> .	O/SB/08) 5) 🔲 I	Notice of Informal Patent Application (P' Other:	TO-152)			

Art Unit: 2815

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 15, 16, 18-20 are rejected under 35 U.S.C. 102(b) as being anticipated by Mandelman et al. The features of the claimed invention are taught by Mandelman which shows an FET with a trench isolation region, such as (31) in Fig. 3, and having a nitride liner (16) located on the sidewalls and bottom wall of the trench. Mandelman also teaches the formation of both NFET and PFET devices at the same time, and specifically mentions that the nitride liner should be used for the NFET devices only, while the nitride liner may be removed from the areas of the chip where the PFET devices are formed (col. 3, I.65-67).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

10/751,831

Art Unit: 2815

Claim 17 is rejected under 35 U.S.C. 103(a) as being unpatentable over Mandelman in view of Divakaruni et al. While Mandelman teaches the basic advantages of using a nitride liner, he does not specifically teach the use of very thin nitride layers between 0.1 to about 2.0 nm. However, Divakaruni, which also forms nitride lined trenches for use in semiconductor devices, teaches that such nitride layers may advantageously be on the order of 1 nm thick. Such a nitride layer would meet the dimension range recited in claim 17. One skilled in the art would be motivated to combine these references because applying a thinner nitride layer would save time and simplify the manufacture of the Mandelman device, while still achieving the desired isolation characteristics.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edward Wojciechowicz whose telephone number is (571) 272-1739. The examiner can normally be reached on Monday through Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (571) 272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

10/751,831

Art Unit: 2815

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Edward Wojciechowicz

Primary Examiner

Art Unit 2815

EW: ew